



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

FICE
 #6/Election
 3/21/02

Group Art Unit: 2818

Examiner: Q. Hoang

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37 CFR 1.8

I hereby certify that this correspondence is being deposited on
February 28, 2002 with the United States Postal Service as
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2/28/02 ✓ Keir & Zube

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RESPONSE TO RESTRICTION REQUIREMENT DATED JANUARY 31, 2002

In response to the Restriction Requirement dated January 31, 2002, having a shortened statutory period for response set to expire on February 28, 2002, Applicants elect claims 1-29, Group I, with traverse, and request reconsideration of the restriction requirement for the reasons discussed below. Although Applicant believes that no fee is due in conjunction with this response, the Commissioner is hereby authorized to charge counsel's Deposit Account No. 20-0782/AMAT/5614/CMP/CMP/KMT, for any fees, including extension of time fees or excess claim fees, required to make this response timely and acceptable to the Office.

THE PENDING CLAIMS:

1. An apparatus for depositing and planarizing a material on a substrate, comprising:
 - a) a partial enclosure defining a processing region and having a fluid inlet and a fluid outlet;